

Comparative Study of Chemical Methods for Fuel Removal

A. Kreter¹, S. Möller¹, C. Schulz¹, D. Douai², H.G. Esser¹, A. Lyssoivan³, V. Philipps¹,
U. Samm¹, G. Sergienko¹, T. Wauters³ and TEXTOR Team

¹Institute for Energy and Climate Research - Plasma Physics, Forschungszentrum Jülich, Association EURATOM-FZJ, TEC, Germany

²CEA, IRFM, Association Euratom-CEA, 13108 St Paul lez Durance, France

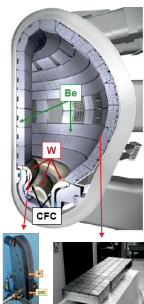
³LPP-ERM/KMS, Association Euratom-Belgian State, 1000 Brussels, Belgium

e-mail:
A.Kreter@fz-juelich.de

FTP/P1-05

Introduction

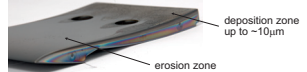
Fuel retention in ITER



- Wall materials, i.e. carbon, are eroded and transported by plasma
- Materials accumulate in remote areas
- Co-deposition of tritium, i.e. in a-C:D layers
- Gaps are additional remote areas, distributed all over the vessel
- Total area of gaps in ITER ~1000 m²

→ **Fuel removal techniques need to be developed and optimized, i.e. for gap cleaning**

Limiter tile from TEXTOR after one campaign



Techniques for fuel removal and vessel wall conditioning

- Application of heat loads**
 - Desorb tritium from the surface or to ablate re-deposition layers
 - Disruption cleaning
 - Photonic cleaning by flash lamps and lasers
- Physical desorption**
 - Ion-induced desorption
 - Conditioning plasma discharge
- Exchange of hydrogen isotopes**
 - Bring non-radioactive hydrogen isotopes in contact with the tritium containing surface in the form of:
 - Gas
 - Conditioning plasma discharge

Chemical etching

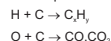
- Based on the chemical reactivity of the removal gases towards the hydrogen isotopes and the wall materials as carbon
- Activation energy is provided by:
 - Active wall heating
 - Thermo-Chemical Removal (TCR), also known as baking in reactive gases
 - Energetic incident particles
 - Conditioning plasma discharge: GDC, ICWC, ECWC

Studies in Forschungszentrum Jülich have been concentrated in recent years on chemical methods including

- Thermo-Chemical Removal (TCR)
- Glow-Discharge Conditioning (GDC)
- Ion-Cyclotron Wall Conditioning (ICWC)

Chemical erosion of carbon by hydrogen and oxygen

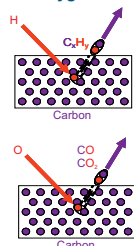
Chemical erosion of carbon:
formation of volatile compounds with impinging species



Co-deposited D/T is released as hydrogen molecule, hydrocarbon or water

Removal rates are functions of

- Surface temperature: According to activation energy of the process
- Impact energy: Enhancement by bombardment with energetic particles (e.g. ions)
- Deeper penetration
- Creation of active sites for other species (synergistic effect)



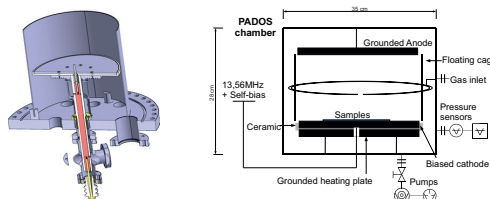
Aim of the study

- Optimize the removal efficiency of each method
- Characterize application restrictions of methods
- Find alternatives to oxygen as removal gas
- Optimize removal from remote areas including gaps
- Propose an integral scheme of fuel removal in carbon containing environment

Experimental

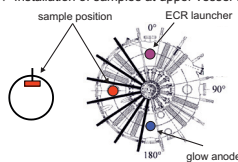
Laboratory device PADOS

- Used for coating of samples by amorphous deuterated layers a-C:D and for TCR
- Capacitive RF discharge between two circular electrodes, \varnothing 25 cm, distance 7 cm
- Option of biasing for lower electrode
- Lower plate is heatable, e.g. for TCR
- a-C:D layers are produced by Plasma Enhanced Chemical Vapour Deposition (PECVD) in methane



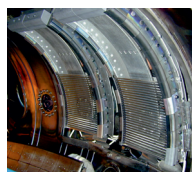
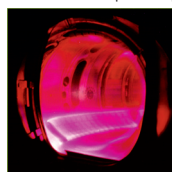
TOMAS toroidal plasma device

- Toroidal vacuum chamber with $R = 0.78$ m, $a = 0.26$ m, $B_0 \sim 0.1$ T
- RF-assisted DC glow discharge between cylindrical anode and grounded wall as cathode: $p \sim 10^{-4}$ mbar, $U_{\text{anode}} = 300$ V, $I_{\text{anode}} \sim 1$ A, $\Gamma_i \sim 10^{14}$ cm⁻²s⁻¹, B_{off}
- ECR discharge at 2.45 GHz, $P = 1.5$ kW, $p \sim 10^{-4}$ mbar, $\Gamma_i \sim 10^{15}$ cm⁻²s⁻¹
- Installation of samples at upper vessel wall



Tokamak TEXTOR equipped with ICRF antennae

- $R = 175$ cm, $a = 46$ cm
- Circular plasma cross-section
- All limiters made of carbon
- Test limiter locks to expose samples
- Frequency 25 - 38 MHz
- Typical ICWC power 2×50 kW
- Operational at $B_0 = 0.2$ -2.5 T

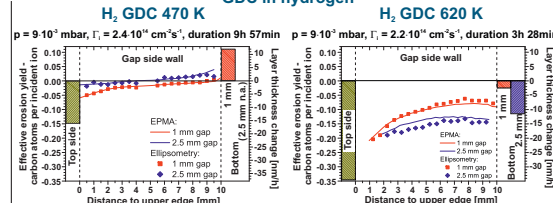


Examples of a-C:D coated samples



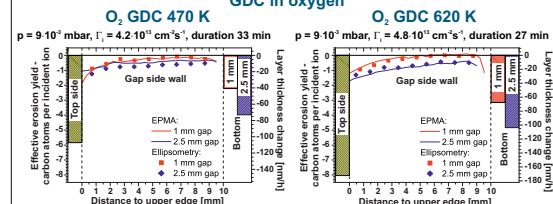
Removal from castellated structures

GDC in hydrogen



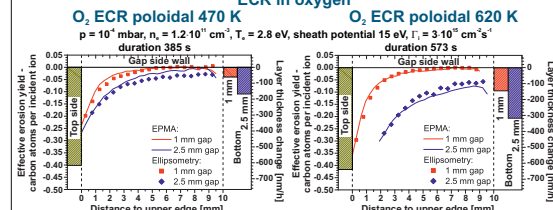
- Erosion of top surface
- Erosion in upper part of gap, deposition in deeper parts
- Net source of C from the plasma (vessel walls)
- Erosion of all surfaces
- Higher erosion in wider gap

GDC in oxygen



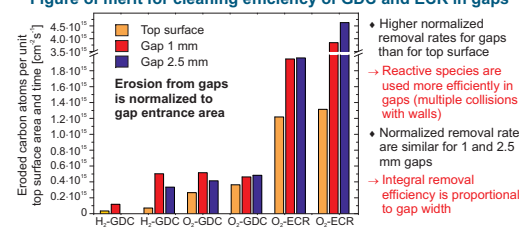
- Higher erosion than in hydrogen, especially top side and gap bottom
- Removal at 620 K slightly more efficient than 470 K

ECR in oxygen



- Lower yields, but higher removal rate than GDC in O₂ (100x higher ion flux!)
- Removal at 620 K slightly more efficient than 470 K
- No significant difference between poloidal and toroidal gaps
- Significant erosion in deep regions of gap despite B field
- Influence of neutrals deep in gap is crucial for ECR

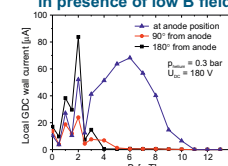
Figure of merit for cleaning efficiency of GDC and ECR in gaps



- Higher normalized removal rates for gaps than for top surface
- Reactive species are used more efficiently in gaps (multiple collisions with walls)
- Normalized removal rates are similar for 1 and 2.5 mm gaps
- Integral removal efficiency is proportional to gap width

Influence of magnetic field

Toroidal symmetry of GDC in presence of low B field

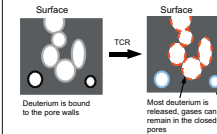


- TCR and ICWC are compatible with high magnetic field, GDC is not
- GDC can be operated at B field of up to ~3 mT
- GDC is compatible with residual fields from ferritic inserts planned for ITER to reduce B field ripple

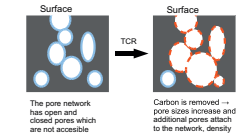
Thermo-chemical removal (TCR)

- Compatible with gap geometry
- TCR at 350°C in oxygen is at least one order of magnitude more efficient than in ammonia
- TCR in ammonia caused delamination of layer
- Potential source of dust
- Can be utilized for first mirror cleaning in ITER
- TCR in oxygen requires elevated wall temperature of >300°C, Arrhenius-type temperature dependence
- Removal is homogeneous in the entire layer due to its porosity
- **Removal rate is proportional to inventory**

TCR: mechanism of deuterium removal



TCR: mechanism of carbon removal



Summary

Removal rates are given for oxygen at wall temperature of 350°C

Removal method	Compatibility with B field	Minimum required wall temperature	Homogeneity of removal	D removal rate [at./m ² h] (for 200 nm)	C removal rate [nm/h] (for 200 nm)
TCR (baking)	Yes	300°C	High, also for remote areas	3 · 10 ⁻¹	50
GDC	OK for <3 mT	Room temperature	High for plasma-wetted areas, limited for remote areas	7 · 10 ⁻¹	170
ICWC/ECWC	Yes	Room temperature	Limited on a part of plasma-wetted area	20 · 10 ⁻¹	600

Projection for ITER

Typical deposition rates in a tokamak discharge:

2 - 3 nm/s at top surface and upper edge of gap and 0.5 nm/s on gap bottom
→ 1000 nm deposition at top surface and at upper edge of gap and 200 nm on gap bottom within one ITER pulse of 400 s

Measured removal rates at 350°C and 1 mm gap:

hydrogen-GDC: 35 nm/h at top surface, 20 nm/h at upper edge and 2 nm/h on gap bottom
→ 100 hours to remove the layer from gap bottom deposited within one ITER pulse

oxygen-GDC: 170 nm/h at top surface, 30 nm/h at upper edge and 70 nm/h on gap bottom
→ 30 hours to remove the layer deposited within one ITER pulse

oxygen-ECR: 600 nm/h at top surface and at upper edge and 150 nm/h on gap bottom
→ 1.5 - 2 hours to remove the layer deposited within one ITER pulse

oxygen-TCR: removal rate is proportional to layer thickness: 50 nm/h at 200 nm, uniformly
→ for layer of >3 μm removal rate is higher than ECR

Proposed combined removal scenario, applied once a week

- Start cleaning of thick layers ~10-100 μm by oxygen-TCR for ~24 hours
- Continue cleaning of remaining layer by oxygen-ICWC and / or oxygen-GDC for ~10 hours
- Thick layer can be removed within one weekend